Comprehensive Analysis of Lithium Niobate Modulators for Optical Fiber Network

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Abstract—Design, fabrication, system requirements, performance, and dependability of contemporary lithium-niobate external-modulator technology are discussed. Current digital communication systems of 2.5, 10, and 40 Gb/s, as well as CATV analog networks, all benefit from the technology's performance and dependability. Higher data rates and deeper integration are becoming the norm in device architecture. Particularly, 10-Gb/s return-to-zero pulse generation in addition to data modulation at high speeds have been realized in a single device.

Index Terms—Electrooptical modulators, lithium niobate, op- tical modulator, waveguide devices.

I. INTRODUCTION

VER Demand for communication services and capacity has increased dramatically over the last decade, establishing the need and

benefits of external modulation in fiber-optic transmission networks. Fiber dispersion limits system performance in high-speed digital communication applications. The bandwidth needed and the methods to reduce dispersion are both provided by external modulators made of lithium niobate (LiNbO3). LiNbO3 guided-wave modulators, in contrast to direct modulation of a laser diode, may be optimized for either zero-chirp or adjustable-chirp operation. Modulators with zero or negative chirp assist reduce system deterioration due to fiber dispersion. To achieve very low modulation distortion in analogue systems, linearized external modulators are often used.

Modern LiNbO3 modulator devices boast temperature stability, low bias-voltage drift rates, and no-bias operation. Due to the improvements in both devices and materials, considerable resources have been put into the development of guided-wave devices. As a consequence, high-quality LiNbO3 modulator components used in fiber-optic communication systems are in great demand and readily available today. In this study, we will discuss the development of LiNbO3 modulator technology up to the current day. Additional context and depth, please. devices and system applications [1], switching technologies [2], and guided-wave devices in general [3] are all discussed in recent publications.

The fundamental methods for creating LiNbO3 guided-wave devices are outlined in Section II of this study. In Section III, we'll talk about the many forms, purposes, and constructions modulator devices may take. The functionality of LiNbO3 devices in electronic circuitry is discussed in Section IV. A few of the analog uses for LiNbO3 modulators are discussed in Section V. Products' life cycles and their potential to be mass produced are covered in Section VI. Section VII discusses the dependability information gathered from real-world use and accelerated testing.

II. DEVICE FABRICATION

Lithium niobate has a very high intrinsic modulation bandwidth, but device switching speeds are limited by a variety of physical constraints. Modulation is produced by a voltage-induced change in the refractive index. The achievable index change is small and, thus, either large voltages or long electrode lengths are needed to obtain sufficient modulation. A useful figure of merit for modulation is the product of the switching voltage and the electrode length. For lengths that allow reasonable voltages, the capacitance of lumped element electrodes would limit the bandwidth to less than 1 GHz. By using travelling wave electrodes, in which the electrical signal propagates along the same direction as the optical wave, much higher bandwidths can be obtained. In this case bandwidths are limited by the mismatch between the electrical and optical propagation constants as well as by the electrical attenuation of the electrode [4]. Theoretical and experimental work has led to electrode structures optimized for 10-Gb/s digital modulation [5].

Fig. 1 depicts a cross-sectional view of an x-cut $LiNbO_3$ Mach–Zehnder interferometer (MZI) modulator, where the critical dimensions of the modulator structure are shown. Wave velocity is a function of the material properties and the waveguide cross-sectional dimensions. Because the modulator can be several centimeters long, preservation of cross-sectional dimensions along the length of a device presents a challenge not only from the standpoint of fabrication but also in the



Fig. 1. Cross-sectional view of an x-cut modulator with coplanarwaveguide (CPW) radio-frequency electrodes.

choice and compatibility of materials used. Required materials include the electrooptic substrate, electrode metal, electrode adhesion layer, buffer layer, and the dopant used for fabrication of the optical waveguides.

A. LiNbO₃ Wafers

LiNbO₃ has been the material of choice for the fabrication of electrooptic modulators due to its combination of high elec- trooptic coefficients and high optical transparency in the near in- frared wavelengths used for telecommunications. Its high Curie temperature (1100 C–1180 C) makes it practical for fabri- cation of low-loss optical waveguides through indiffusion of metals [6]. LiNbO₃ is also thermally, chemically, and mechani- cally stable and is compatible with conventional integrated-circuit processing technology.

Wafers with high optical homogeneity and surface flatness are needed in the fabrication of integrated optical devices. LiNbO₃ wafers are obtained from boules grown using the Czochralski technique. During the growth process, care is taken to ensure that Fe ion contaminants are eliminated, or kept to a minimum, in order to reduce the susceptibility of the crystal to photorefractive optical damage. LiNbO₃ is particularly suscep- tible to optical damage at wavelengths below 1 m. However, for wavelengths greater than 1 m, photorefractive damage is generally negligible for optical powers less than 100 mW.

LiNbO₃ wafers with diameters up to 100 mm are commer- cially available in different crystal cuts (x-, y-, and z-cut) with the choice of cut depending upon the application. The handling of x- and y-cut wafers during the fabrication process is fairly straightforward, whereas z-cut wafers require special handling procedures because the crystal's piezoelectric and pyroelectric properties produce electrical charge accumulation on the z-faces during processing. Modulators made on z-cut wafers also require special design and packaging to minimize bias drift due to charge migration and the buildup of pyroelectric charges.

B. Waveguide Fabrication

 $LiNbO_3$ waveguides have been traditionally fabricated by in-diffusion of Ti at temperatures near 1000 C. The process is straightforward, but precautions must be taken to suppress the out-diffusion of Li from the surface of the substrate. A Li-defi- cient surface results in an unwanted planar waveguide for z-po-larized light and can seriously affect modulator performance. The presence of Ti in the crystal increases both the ordinary and the extraordinary indexes of refraction. Hence, for suitable

doping concentrations, both TE and TM modes will propagate along the waveguides.

An alternative method for fabricating LiNbO₃ waveguides is through the annealed proton exchange (APE) process [7]. Proton exchange [8] is a lowtemperature process (~120 C-250 C) whereby Li ions from the LiNbO₃ wafer are exchanged with protons from an acid bath. Proton exchange can only be applied to xand z-cut wafers; the acid chemicallyetches y-cut wafers. Exchanged layers exhibit an increase in the extraordinary index; the ordinary index is left virtually undis- turbed or even reduced. APE waveguides are, consequently, polarizing waveguides. The proton exchange is followed by a high-temperature anneal. The annealing step in the APE process is crucial in obtaining high-quality electrooptic waveguides. The annealing process successfully addresses the problems of index instability [9], [10] and deterioration of the electrooptic effect [11] exhibited by proton-exchanged waveguides without anneal. Accelerated aging studies carried out on x-cut APE directional couplers and Mach-Zehnder modulators have shown no degradation of device performance over a 13-year lifetime at 125 C and a 25-year lifetime at 95 C [12], [13].

Preservation of waveguide cross-sectional properties across

the wafer requires good uniformity in Ti film deposition as well as uniformly flat thermal zones in furnaces used for the diffusion or exchange/anneal processes. Careful screening of wafers for surface flatness is key to minimizing waveguide-width variation across the wafer during mask definition by photolithography. Last, process parameters such as Ti film thickness, diffusion temperature, and time can be tailored to yield high-quality stripe waveguides, which exhibit low propagation loss, optimum field confinement, and good waveguide-to-fiber coupling.

Almost all commercially available 2.5- and 10-Gb/s LiNbO₃ modulators use stripe optical waveguides. As modulation speeds increase to greater than 20 Gb/s, ridge waveguides on z-cut sub- strates will be required to achieve lower drive voltages and re-duce device lengths [14]. A ridge waveguide under the active (or "hot") electrode concentrates the flux of the applied electric field within the waveguide and provides tighter confinement of the optical mode. Both effects increase the overlap between the applied electric field and the optical mode in a z-cut arrange- ment, thus providing a lower switching voltage. LiNbO₃ ridges a few micrometers deep can be obtained by wet etching [15],

[16] or ion-milling [17] techniques. Smooth ridge sidewalls as well as good control of etch depth and sidewall direction are key in achieving low-loss waveguides with good mode confinement.

C. Electrode Fabrication

RF electrodes are fabricated either directly on the surface of the LiNbO₃ wafer or on an optically transparent buffer layer to reduce optical loss due to metal loading and provide a means for optical/RF velocity matching. In general an adhesion layer, such as Ti, is first vacuum deposited on the wafer, followed by the deposition of a base layer of



Fig. 2. SEM picture of 18- m-thick gold-plated CPW electrodes at a region where the electrodes are making a bend.

the thick mask and to ensure that the electroplating process pre-serves the cross-section of the RF electrode along the length of the device.

Gold is generally used as the electrode metal. Plating pro- cesses yielding high-purity metal, small grain size, minimum feature distortion, and reasonable plating rate are key to obtaining good RF performance. Various plating chemistries, dry or in solution, are commercially available. Each chemistryworks best in conjunction with a particular continuous and/or pulsed current supply as well as a particular mask material. After plating, the mask is removed and the metal in the gaps is etched away. Fig. 2 shows a scanning electron microscope (SEM) picture of a typical gold-plated coplanar-waveguide electrode fabricated for a 10-Gb/s digital modulator.

D. Dicing and Polishing

In contrast to semiconductor materials such as GaAs or InP, LiNbO₃ substrates do not cleave readily. Substrates containing an array of finished modulators are cut from the LiNbO₃ wafer using conventional water-cooled diamond saws. The substrate end faces are cut at an angle to the waveguides in order to elimi- nate reflections and are then polished to an optical finish. A good optical finish and a sharp edge are required at both the input and output optical facets of the device to ensure good fiber-to-wave- guide coupling. For ease of handling, the modulators on a substrate are individually tested before the substrate is diced into individual components.

Cleanliness must be maintained throughout the modulator fabrication process. Debris from dicing and particulates from polishing compounds are contaminants that can negatively im-pact the performance and long-term the metal in which the electrodes are to be made. The electrode pattern is then photolithographi- cally defined. High-speed modulators incorporate RF electrodes whose thickness can range from a few micrometers to greater than 15 m. Special lithographic processes are needed to define

reliability of the modulators, and must therefore be removed during chip cleaning operations.

E. Pigtailing, Packaging, and Test

To utilize $LiNbO_3$ modulators in real-world applications, the integrated-optic chip must be pigtailed and packaged in order that optical and electrical signals can be efficiently and effec-

tively directed into and away from the device. Three principle subassemblies or subcomponents are used in the manufacture of packaged LiNbO₃ modulators. The three subassemblies are, namely, the integrated-optic chip, optical-fiber assemblies, and electrical or RF interconnects and housing. The fabrication of the integrated-optic chip was described in detail in the preceding paragraphs of this article.

LiNbO₃ modulators can be packaged in either hermetic or nonhermetic housings, depending upon the application, oper- ating environment, and methods and materials utilized in the modulator manufacturing process. Reference [18] provides a comprehensive description of the packaging techniques used to produce hermetically packaged LiNbO₃ modulators. For de- vices designed to operate within telecommunication central-of- fice environments, nonhermetic packaging has proven both suf- ficient and cost effective for meeting the necessary reliability and qualification requirements [19].

Due to the polarization dependence of the electrooptic effect, the polarization state of the input light supplied to the modu- lator must be carefully controlled and maintained to achieve optimum performance. Hence, most LiNbO3 modulators uti- lize polarizationmaintaining fiber for the input pigtail, while the output fiber is typically standard single-mode fiber. During the preparation of the input and output optical fiber subassem-blies, a small tube or block is attached to the end of each fiber. This tube is angle cut and polished to minimize back-reflections from the fiber-to-LiNbO3 interface. The tube also increases the surface area and bond strength of the pigtail joint, thereby en- suring longterm stability and reliability. Ultraviolet-curing or thermal adhesives are used to attach the fiber subassemblies to he LiNbO₃ chip. The fiber subassemblies are typically

directional coupler type [21]. In the MZI, light is split into two optical paths that are isolated from one another. The applied electric field from an electrode modifies the relative velocities of the two beams via the electrooptic effect, resulting in variable interference when the two paths are recombined at the output. In the directional coupler approach, light is injected into two modes of a waveguide structure. The applied field modifies the relative velocities of the two modes as well as the coupling be-tween the modes. The two most common examples of the direc-tional coupler type are the reversed delta- β coupler [22] and the digital optical switch [23]-[27]. The reversed delta- β coupler is compact and can be tuned with modest voltages (10-20 V). The digital optical switch requires higher drive voltages (40-50V) but can be constructed as a polarizationindependent switch. The MZI works well with highbandwidth electrode structures requiring tens of micrometers of spacing between waveguides, and long electrodes are needed to reduce drive voltages (≤ 6 V). The directional-coupler-type switches are typically used for lower speed switching applications where small size and polar-ization diversity may be required, and tight electrode gaps (<10

µm) are more easily accommodated.

The first choice encountered in designing a $LiNbO_3$ modu- lator is the orientation of the crystal axes to the

designed with a strain-absorbing bow to accommodate the differential thermal expansion among the LiNbO₃ chip, the fiber, and the metallic housing [18].

Electrical interconnects are attached and soldered to the mod- ulator housing, thereby creating the third subassembly. The pig-tailed LiNbO₃ chip is attached to the package using a compliant adhesive that mechanically decouples the optical assembly from the package and absorbs thermally induced strains [20]. Last, electrical interconnection between the package and the LiNbO₃ chip is accomplished using either wire or ribbon bonds. For high-frequency operation, the dimensions of the bond must be carefully controlled to achieve optimal performance.

Once all three subassemblies are copackaged, the modulator must be sealed and tested as a completed, functional unit. Keyparameters that are typically measured during final test include: optical loss, switching voltage, optical on/off extinction. bias stability. and microwave/RF properties such as S_{11} and S_{21} . Oftentimes, some of these performance parameters are measured over the operating temperature range of the device. Bit-error-rate and eye-diagram measurements are not typically required on each production device. These measurements are often performed during the design verification and validation stages of product development, and only the aforementioned parameters need to be measured in production.

III. DEVICE DESIGN

The basic building blocks for lithium niobate modulators and switches generally fall into one of two categories: MZI type or

waveguides and electrodes. The crystal cut affects both modulator efficiency, as denoted by half-wave voltage V_{π} , and modulator chirp, which is described by the chirp parameter . The difference is apparent in Fig. 3, which shows the four most common electrode structures used in MZItype switches. The strongest component of the ap-plied electric field must be aligned with the -axis of the crystal, which has the highest electrooptic coefficient. This requires that the waveguide be placed between the electrodes for an x-cut configuration and beneath the electrodes for z-cut. Because the electrodes are placed on top of the waveguides, z-cut devices always require a buffer layer to minimize attenuation of the op-tical mode due to metal absorption. Z-cut devices also typically employ conductive buffer layers and charge bleed layers to mit-igate dc drift and pyroelectric charge buildup, respectively [18]. X-cut devices do not inherently need a buffer layer because the electrodes are not placed directly above the waveguides; how-ever, to achieve multigigahertz operation, broad-band x-cut de-vices do use a buffer layer for velocity matching of the RF andoptical waves.

The applied electric field and electrooptic efficiency of various electrode topologies can be modeled using quasistatic techniques such as finite-element or finite-difference methods [28]. These techniques also provide the microwave properties of the electrode (velocity, impedance, and loss). RF loss can also be adequately determined at high frequencies (>2 GHz) with Wheeler's inductance rule [29]. In general, thick electro-plated electrodes (\geq 15 m) have low RF loss (\leq 0.5 dB cm⁻¹ GHz^{-0.5}) and enhanced velocity matching due to the presence of electric flux in the air gap between electrodes. Buffer layers are required for broad-band velocity matching on both x- and z-cut devices due to thehigh RF dielectric constants of lithium niobate () relative to theoptical dielectric constants ().

X-cut electrode topologies [Fig. 3(a) and (b)] result in chirp-free modulation due to the push-pull symmetry of the









Fig. 3. Most common electrode configurations for (a) nonbuffered x-cut, (b) buffered x-cut, (c) buffered single-drive z-cut, and (d) buffered dual drive z-cut.

applied fields in the electrode gaps. In z-cut devices, the waveguide positioned underneath the hot electrode experiences an RF field flux that is more concentrated, resulting in a factor of two improvement in overlap between RF and optical field, relative to x-cut. However, the overlap under the z-cut ground electrode is reduced by a factor of three, relative to x-cut; therefore, the overall improvement in z-cut V_{π} (relative to thex-cut V_{π}) is only about 20% for single-drive modulators. The difference in overlap between the two z-cut waveguides results in a chirp parameter of approximately -0.7.

By employing a dual-drive topology, in which the push–pull effect is produced by the driver circuit, the factor of two im-

Ele	ectrode / crystal cut	Application	Electrode Length				
Non-buffered x-cut		2.5 Gb digital	1.0				
Buffered x-cut		10 Gb digital	2.2				
x-cut narrowband		10 Gb RZ pulse	1.5				
z-cut single drive		10 Gb digital	2.2				
z-cut dual drive		10 Gb digital	2.2				
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-4	z-cut single drive z-cut dual drive	x-cut narrowband					
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^{0.0} Frequency (GHz) ²⁰							

Fig. 4. Calculated electrooptic response for several devices designed for broad-band digital or RZ pulsing applications at 2.5 or 10 Gb/s using conventional electrode and waveguide structures (no ridges or n enhancement). Electrode lengths were chosen to be representative of devices used in actual applications and are shown in Table I.

provement in overlap under the hot electrode can be utilized inboth arms of the MZI at the expense of increased RF circuit complexity. Balancing the two drive levels results in zero-chirp operation. Imbalancing the two drive levels provides electroni-cally programmable chirp.

Nonbuffered x-cut is the overall winner in electrooptic effi- ciency per unit length, having about a 30% lower than the z-cut waveguide beneath the hot electrode. Unfortunately, ve- locity mismatch of nonbuffered x-cut limits bandwidth, and the 25- electrode impedance introduces additional penalties due to impedance mismatch and RF loss. RF electrodes on buffered x- and z-cut substrates can be designed for velocity matching and impedances near 40.

A number of methods have been employed to enhance the electrooptic efficiency. Ridge waveguides further enhance the focusing of electric flux under the hot electrode and have been used to demonstrate V_{π} of 3.5 and 5.1 V for z-cut modulators with 30- and 70-GHz bandwidths (3 dB electrical), respectively [28]. A 15% reduction of V_{π} has also been demonstrated by using ridge structures in an x-cut device without a buffer layer and by using lumped-element (low-frequency) electrodes [30]. The overlap between the applied electric field and the optical fields can also be improved in both x- and z-cut by increasing the waveguide refractive index and narrowing the ground electrodewidth [31].

The electrooptic efficiency at modulation frequency can be improved at the expense of bandwidth by using RF phase-matching techniques such as phase reversal or intermit- tent-interaction electrodes [32]. These narrowband techniques allow the buffer/electrode structure to be optimized for the best field overlap, while RF phase-

matching is achieved by flipping the polarity of the electrooptic interaction periodically, or by moving the electrode away from the waveguide when the walk-off between RF and optical fields exceeds 180. More complex electrode structures allow further improvement in phase-matching while still maintaining the high level of field overlap, resulting in approximately 40% improvement in modulation efficiency compared to phase reversal [33].

Fig. 5. Calculated electrooptic response for the case where all modulators have a 5-cm electrode length (conventional electrode and waveguide structures, no ridges or n enhancement).

TABLE I NORMALIZED ELECTRODE LENGTHS USED IN CALCULATION SHOWN IN Fig. 4

Narrow-band devices are well suited for return-to-zero (RZ) pulsing applications because the pulse generator is typically driven with a sinusoidal signal at the clock frequency [34].

The electrooptic efficiency versus modulation frequency is compared in Figs. 4 and 5 for the various electrode geometries and crystal cuts of Fig. 3. A narrowband x-cut modulator for RZ pulsing is included as well [33]. The response curves rep- resent electrical power at the receiver's photodetector per unit of total electrical power into the modulator (add the power into both ports for dual drive). Conventional electrode and wave- guide structures are assumed [28], [35], that is, CPW electrodes are assumed and no ridges or enhancement are utilized. RF properties and RF-optical overlap have been calculated using fi- nite difference quasi-static field analysis. Optical mode profiles typical of conventional single-mode stripe wave-guides are used in the RF-optical field overlap calculation. The electrode prop-erties and dc electrooptic efficiency are inserted into an elec- trooptic response model that accounts for reflections from the RF termination [35].

Fig. 4 shows the calculated electrooptic response for several devices designed for broad-band digital or RZ pulsing transmis- sion applications at 2.5 or 10 Gb/s using conventional electrode and waveguide structures (no

ridges or enhancement). The electrode lengths were chosen to be representative of devices used in actual applications and are shown in Table I, normal- ized to the shortest electrode (nonbuffered x-cut). The applica- tion for which each device would be best suited is also listed in Table I. Fig. 5 shows the electrooptic response for the case where all modulators have a 5-cm electrode length. Note that

the plots in Figs. 4 and 5 are of the same format as an S_{21} (elec- trooptic electrical dB) network analyzer measurement. RF loss from packaging is neglected in the plots of Figs. 4 and 5, in order that raw electrooptic performance can be compared.

The comparison of electrooptic efficiency in Fig. 4 reveals some interesting results. As expected, z-cut dual drive is the most efficient, given its long length, velocity matching, and high overlap efficiency. The 4-dB advantage over buffered x-cut is mainly due to the factor-of-two improvement in RF-optical overlap minus the 3-dB penalty for two inputs. Single-drive z-cut only boasts a 2dB advantage over buffered x-cut, and is surpassed slightly at 10 GHz by narrow-band x-cut, which is 30% shorter. Nonbuffered x-cut begins near the efficiency of z-cut single drive, but rolls off faster due to RF-optical velocity mismatch. Note that the improved performance of zcut dual-drive device comes at the expense of greater sophistication in delivery of RF drive signals to the modulator, a complication that is an issue at 10 Gb/s and becomes problematic at higher bit rates such as 40 Gb/s.

The electrooptic efficiency for the case where all electrodes are 5 cm is shown in Fig. 5. The narrow-band xcut device is the overall winner at 10 GHz, even surpassing the z-cut dual-drive structure by about 1 dB. The low RF electrode loss and high overlap efficiency of the narrowband electrodes on nonbuffered x-cut substrates account for the improved performance. In the narrow-band design, the RF loss can be minimized with little constraint from velocity or impedance-matching concerns, a de- gree of freedom that becomes significant for longer electrode lengths.

One other factor that affects modulator design is bias voltage drift. For MZI type modulators, the optical output power versus drive voltage transfer function is sinusoidal, with the ideal bias point near the half power point (quadrature). Quality of trans- mitted digital data can suffer if the bias point shifts too much over time, generally requiring an active feedback circuit to mon- itor and adjust the bias voltage. Alternatively, the bias point can be preset in manufacturing, eliminating the need for a feed-back circuit, or at the very least reducing the level of applied dc voltage. The long-term dc drift behavior is best described by an RC ladder model [36]. The initial applied field is determined by capacitive voltage division through the ladder. The long-term field is determined by resistive voltage division. The resistors and capacitors in the model are set by process parameters and conditions used to fabricate the waveguides and electrodes. Ac- celerated aging tests reveal that bias voltage for a device using Ti indiffused waveguides will not change by more than a factor of two from the initial bias voltage, over a 20-year

lifetime at typical operating temperatures.

Lithium niobate modulator technology easily accommodates integration of multiple functions. The level of integration is mainly limited by the size of the wafer and the length of the different building blocks. A simple example of integration is a series cascade of a low-speed MZI and a high-speed MZI to form a variable optical attenuator plus data modulator. The efficiency per unit length of the narrow-band x-cut electrode permits an RZ pulse generator to be integrated in series with a broadband data modulator [33]. Alternatively, an MZI and phase modulator can be integrated, both having narrowband

electrode structures, to form a chirped RZ pulse generator [33] needed for long-distance transmission [34], [37]. Integration of MZI's in series or parallel has been proposed and demonstrated for linearization of the transfer function for cable TV and other analog transmission applications [38]–[40]. Last, hybrid integration of photodetectors with the lithium niobate chip is readily accomplished for power monitoring functions.

IV. SYSTEMS REQUIREMENTS AND DIGITAL

PERFORMANCE In recent years, LiNbO₃ devices have

successfully addressed

the modulation requirements in digital fiber-optic timedo- main-multiplexed (TDM) and wavelength-divisionmultiplexed (WDM) systems. Modulators have become a critical com-ponent in the majority of today's long-haulterrestrial and submarine optical networks. The appropriate modulator archi- tecture is chosen for a given system implementation based on performance criteria and transmission format.

When designing and characterizing a fiber-optic transmis- sion system, a baseline measurement of the transmitted signal is made at the modulator output through analysis of the signal's time-domain properties. This modulated optical signal is then launched into the fiberoptic link. Signal degradation, resulting from numerous fiber processes, amplifier noise, and other link components, is quantified by measuring the detected signal. A measurement of the bit error rate (BER) determines the accu- racy with which the optical receiver is able to differentiate be- tween digital "one" and "zero" bits. This fundamental challenge of maintaining signal quality through the optical fiber link de- termines the performance requirements of the modulator.

The predominant technique used for telecommunications transmission in optical fiber has been on–off keying (OOK), or intensity modulation with direct detection, where the optical intensity is gated in a shuttering fashion. Data encoding has predominantly utilized a nonreturn-to-zero (NRZ) format, where an arbitrary data stream of "one" and "zero" symbols is directly encoded as high and low optical powers, respectively. Advantages of OOK include minimizing the fiber link degrada- tion due to group velocity dispersion, because NRZ data coding provides a narrow-spectrum signal, and ease of data recovery at the receiver. OOK is adequate for links operating at data rates of 2.5 Gb/s for spans up to 1000 km and 10 Gb/s for spans up to 500 km, utilizing traditional and nonzero-dispersion-shifted singlemode fibers.

A typical NRZ transmitter incorporating a LiNbO₃ modulatoris shown in Fig. 6. Digital OOK waveforms are typically pre- sented in the form of an "eye" diagram, which is the superpo- sition of all "one" and "zero" states of a pseudorandom bit se- quences (PRBS) within one bit window. Fig. 7(a) and (b) shows LiNbO₃ externally modulated eyes at 2.5 and 10 Gb/s, respec- tively.

The center of the eye is required to receive no light intensity, or "hits," since the receiver decision circuitry operates in this region using a preset intensity threshold. A larger "no-hit" zone improves the accuracy of the receiver and lowers the BER. Since the processes that degrade the eye are typically stochastic in na-ture, long sampling times of the transmitted signals are required to accurately quantify the system's BER. Transmitter metrics,



Fig. 6. Data modulator topology for NRZ transmission.





Fig. 7. LiNbO3 externally modulated eyes at (a) 2.5 and (b) 10 Gb/s.

including average launch power, optical extinction ratio, tran- sition rise and fall times, timing jitter, transition crossing per- centage, and Q parameter, have been developed to quantify the quality of the digital signal. The key performance parameters

of the modulator that impact these metrics, and therefore de- termine system performance, are switching voltage, S_{21} elec- trical-to-optical response, S_{11} electrical return loss, optical ex- tinction ratio, excess optical loss, and optical chirp of the mod-ulated signal.

The S_{21} parameter relates the modulator's highfrequency switching voltage to the electrooptic efficiency of the device at low frequency, usually denoted as V_{π} at dc. Practical implemen- tations of digital systems can tolerate up to 3-dB rolloff in effi-ciency at the highest frequency in the modulated signal's spec-trum. In digital systems, the requirement for wide-band opera-tion is driven by the nature of the data signals, which are, by def- inition, random with continually varying frequency content. As an example, for 2.5-Gb/s operation, the 3-dB bandwidth of the S_{21} response is normally specified to be greater than 2.2 GHz. The phase linearity of the S_{21} electrooptic response, describing the linear phase offset error during the electrical-to-optical con-version at a particular frequency, must be less than ± 5 over the operating frequency band. The S_{11} parameter, or the elec- trical return loss at the modulator drive port, is also of great im-portance. The value must typically be less than -10 dB, in order that the reflected power returning to the high-speed drive electronics is low and that there is <5% reduction in electrooptic conversion efficiency.

The optical extinction ratio describes the ability of the device

to extinguish the light when the modulator is driven to a "zero" state. The extinction ratio is typically required to be greater than 20 dB at dc for digital applications. Variation in the modulator's electrooptic response with frequency and

some small amount of reflected RF power between the modulator and driver reduce the observed extinction ratio for a PRBS signal. The optical "eye" extinction is one of the most important figures of merit for the signal, especially when cascading a number of link sec-tions and optical amplifiers. From [41], the expression for link power penalty as a function of extinction ratio is

where is the linear ratio of ON power to OFF power. An in- crease in extinction ratio from 10 dB () to an extinc-tion ratio of 20 dB () results in ~0.8-dB improve- ment in receiver sensitivity. For appropriately designed trans- mitters utilizing LiNbO₃ modulators, 20 dB extinction at fre- quency and >90% eye opening has been demonstrated at 2.5 Gb/s. These transmitters readily maintain >15 dB extinction under all operating TABLE II MODULATION FORMATS

conditions. At 10 Gb/s, >15 dB extinction has been achieved at frequency and >13 dB maintained over all conditions.

Modulator chirp must be taken into consideration in the link design, due to its interaction with dispersive effects. One of the major strengths of $LiNbO_3$ modulators is that they can be de- signed to have zero chirp and suffer no link length penalty due to dispersive interaction. However, to

$$Ppen(r) \approx -10 \cdot \log\left[\frac{r-1}{r+1}\right]$$

solve some of today's higher bit-rate problems, the ability to design a nonzero-chirp $LiNbO_3$ modulator has also proved important. The design of the mod- ulator's chirp value is used as a degree of freedom, which can be leveraged to extend link distances. Chirp has been shown to

Modulation Technique	Optical spectra	Data format	Comments
AM – NRZ (Amplitude Modulated – Non-Return –to-Zero)	Double sideband, with carrier	NRZ (typical)	Bandwidths typically twice the information bandwidth (or more), significant carrier power.
AM - RZ (Amplitude Modulated Return-to-Zero)	Double sideband, with carrier	RZ	Bandwidths typically 4 times the information bandwidth (or more), significant carrier power
SSB (Single Sideband)	Single sideband	NRZ	Bandwidths ½ AM bandwidths Increased dispersion tolerance
DSSC (Double-Sideband Suppressed Carrier)	Double sideband suppressed carrier	Duo-Binary	Requires special modulation techniques, external modulator typically used
PM (Phase Modulated)	Phase modulation	РМ	Used for linewidth broadening and dispersion compensation.

Fig. 8. Pulse-data modulator topology for RZ transmission.



enhance the transmission distances at 10 Gb/s by 25% (from 80to 100 km) [42].

The very high DWDM channel loading (100 channels or more), the increased bit-rate requirements of nextgeneration systems, and the desire to build wavelengthintelligent net- works has pushed the capabilities of the NRZ transmission to its limits. Hence, other data-encoding formats and modulation techniques, as described in Table II, are being considered to improve system performance. Lithium niobate affords the advantages of a customizable modulator device technology that can be used to supply enabling building blocks for these alternative modulation formats and techniques.

The return-to-zero modulation format has been

employed in recent high-bandwidth terrestrial and submarine systems, especially those requiring long transmission distances. Dis- persion managed soliton and other narrow-pulse transmission techniques can be considered specialized versions of RZ trans- mission. In conventional NRZ pulse format, the interaction between self-phase modulation (SPM) and group velocity dispersion (GVD) causes the transfer of energy from the center of the pulse toward the pulse edges [43], [44], a situation that is enhanced for a stream of "ones." Crossphase modulation (XPM) worsens for a stream of "ones," as well, due to the increased cross-wavelength interaction time. Use of the RZ format in a dispersion-managed system greatly reduces SPM and GVD pulse deformation, resulting in greater pulse-to-pulse consistency. The improved performance permits lower optical power levels, due to the reduced duty cycle, which in itself provides additional relief from the nonlinear effects.

RZ modulation increases the demands on bandwidth and phase linearity for both the modulator and the drive electronics.

Hence, modulator suppliers have designed multistage LiNbO₃ devices, which ease these requirements.

Specifically, the bandwidth requirement for the higher spectral-width RZ format is divided into two optical stages, each with lower frequency drives. Fig. 8 shows a RZ transmitter topology implemented using a two-stage LiNbO₃ device. The output of such a RZ transmitter is shown in Fig. 9. NRZ input signal and RZ transmitted data at 10 Gb/s are shown in Fig. 9. These RZ transmitters have also been extended to include a third stage, which provides phase modulation, used to synchronously chirp the pulse train and extend even further the transmission link span.

The ability to integrate multiple functions into a single com-ponent has been a powerful attribute of $LiNbO_3$ modulators, driven by the desire to solve system-related challenges using the capabilities of the $LiNbO_3$ chip. Multifunction $LiNbO_3$ components can be realized with a variety of integrated-optical structures connected in series, parallel, or a combination of both.

Parallel-integration approaches are attractive in areas of the network where signals pass through multiplexers and demultiplexers. In these cases, many wavelengths, propagating in separate fibers, are present on a single card and arrayed devices (the integration of multiple-parallel channel paths on a single chip) are particularly useful. Applications such as photonic switching [45], channel-to-channel attenuation, and 3-R regeneration within line equipment are some of the drivers for parallel-integration technology.

In other applications, multiple component functions are inte-grated in series. For example, an integrated phase modulator and amplitude modulator can be used to provide adjustable chirp to the modulated signal launched into a network, allowing for ex-



Fig. 9. Acquired waveforms of 10-Gb/s NRZ and RZ data.

tended reach in networks using dispersive fiber. Another prac- tical example of serially combining functions is the integra- tion of the optical data modulator with an on-chip variable at- tenuator. Today's DWDM systems require channel-to-channel variable attenuation for dynamic power equalization [41] and full channel blocking during live-card installations (hot swaps). Today, several LiNbO₃ component suppliers are integrating the attenuation and modulation functions into a single package.

Future-generation wavelength-agile networks will require modulation components to be wavelength independent and to operate in wavelength bands outside the traditional C-band of 1530–1565 nm. New systems are encompassing the L-band of 1570–1610 nm. Lithium niobate modulators have been designed to maintain low loss and constant switching voltage over the 1530–1610-nm wavelength range. As optical-amplifier technology matures, new markets will develop for modulators and other optical components at many wavelengths. Lithium niobate's broad wavelength flexibility will be invaluable in con- struction of these devices. As an example, future networks may use tunable lasers to provide wavelength-selectable transmission sources to add functionality, such as wavelength routing, and to help solve sparing and inventory issues [47]. Tunable laser transmitters require the use of an external modulator in order to provide a high-quality transmission signal, while maintaining wavelength-stabile operation. The modulator must have a broad-band response to wavelength in order to provide consistent performance over the entire tuning range of the laser. Laboratory demonstrations of tunable lasers, modulated with LiNbO3 modulators, have been successfully performed.

V. NONDIGITAL APPLICATIONS

In the environment of the late 1990's, where WDMbased digital systems are being deployed in high volume, it is easyto overlook the equally important role of $LiNbO_3$ modulators in nondigital applications. Commercially available $LiNbO_3$ mod-ulators are today being deployed in a variety of lower volume

nondigital communications applications, such as CATV signal distribution and wide-band microwave signal distribution and antenna remoting.

It is generally accepted that high-quality, "head-end" CATV signal distribution (typically, 40–860 MHz) was the first truly successful commercial application of LiNbO₃ external modu- lator technology. State-of-the-art CATV modulators are special- ized, high-performance devices. They typically include an am-plitude modulator, a phase modulator for suppression of stimu-lated Brillouin scattering, a separate bias port, and two comple- mentary optical outputs. The amplitude modulator must have a flat electrooptic (S_{21}) response (±0.5 dB) and low electrical re-turn loss (< -18 dB). An extensive review of external mod-ulation for CATV signal distribution can be found in [48].

Traditionally, electronic predistortion of the CATV

cable or heavy metallic waveguides. For this reason, highspeedexternal modulators have been the object of intense research and development since the inception of LiNbO₃ guided-wave devices. In the last few years, packaged LiNbO₃ devices with bandwidths in excess of 40 GHz [51] have been demonstrated. Responses up to 100 GHz have been measured in a probed device [52].

In spite of these recent advances, the deployment of true mi- crowave frequency links has not been widespread. They have typically been limited to military and aerospace applications where multioctave bandwidths and longdistance transmissionfor microwave frequencies are required [53]. These applications include radar delay lines, towed aircraft decoys and wide-band antenna remoting for distances greater than 100 m.

The widespread acceptance of multigigahertz links has been hampered by the relatively high drive voltages required by com- mercially available modulators, typically in the 6-10 V range at 10 GHz, and even larger at higher frequencies. Modulator drive voltages of this magnitude require signal amplification in the 35-45 dB range, assuming about 2-3 mA of detector current. Unlike digital systems whose wide-bandwidth signal is carried directly as generated, RF distribution systems have the option of down-conversion to lower frequencies, which can be transported with much lower losses on standard coaxial cables. For LiNbO3 to achieve widespread deployment in wide-band. multigigahertz analog systems, a truly transparent link (0 dB electrical loss) is needed. This requires an increase in modulation efficiency by one or two orders of magnitude. A detailed treatment of inten-sity modulation in analog fiber-optic links may be found in [54].

electrical

signal has been required in order to limit the inherent nonlinear, odd-order distortion products arising from the optical modu- lator [49]. The development and successful commercialization of optically linearized modulators has virtually eliminated the need for such electronic predistortion and its associated finely tuned predistortion circuitry [50]. Either method can be used to transmit signals with low distortion and high carrier-to-noiseratio.

One example of an optically linearized modulator uses two independent amplitude modulators connected in series via a di-rectional coupler. A second directional coupler is required at the output of the second amplitude modulator. The RF input (am- plitude and phase) to each of the two series modulators is con-trolled separately. In order to achieve adequate reduction of the distortion product, the linearized modulator requires that the two directional couplers be fabricated with coupling angles within 2% (i.e., 4) of one another. This represents a fairly tight, yet achievable, manufacturing tolerance.

The flat attenuation-versus-frequency characteristic of optical fiber makes it an ideal medium for microwave and millimeter-wave transmission, as opposed to lossy coaxial

MANUFACTURABILITY Like all manufactured products,

the manufacturability of

LiNbO₃ electrooptic modulators is established in the product design and development cycle. The job of the product devel- opment team is to anticipate and understand the manufacturing issues in order to generate product designs that meet high performance requirements and that can be built in volume on the production floor. The primary challenge in realizing a manufacturable design during the product-development process stems from the tradeoffs among performance, "standard" man-ufacturing process capability, and development time.

The importance of "time to market" in the photonic telecom- munications industry cannot be underestimated. Because the industry is moving at an extremely rapid pace, product-devel- opment cycle time is as critical as performance. This is espe- cially true for photonic components, like LiNbO₃ electrooptic modulators. System engineers need components that meet per- formance specifications, but they also need components that are available in the time frame of their system design window. In addition, the device design must be able to rapidly transi- tion to high-volume production to meet the demands of today's fast-paced communications market place.

Modular designs that use standard design elements and standard manufacturing processes enable the reduction of product-development cycle times, while simultaneously en- suring manufacturability. Standard manufacturing processes used in the production of LiNbO₃ electrooptic modulators can



Fig. 10. The generic sequence of steps required to produce $LiNbO_3$ electrooptic modulators.

be categorized into three general groups. These are integrated optical circuit fabrication, device packaging, and testing. Each of these can be further categorized. For example, integrated optical circuit fabrication consists of waveguide processes, buffer layer processes, electrode processes, etc. Device pack- aging consists of RF interconnection, optical interconnection, soldering and sealing processes, etc. Testing consists of in-process testing, wafer-level testing, final device testing, etc. The generic sequence of steps required to produce LiNbO₃ electrooptic modulators is shown in Fig. 10.

Standardization within each process across different

TABLE III FIELD FAILURE RATES FOR LiNbO₃ MODULATORS

FIELD DATA	2.5 Gb/s, X-Cut, Ti Waveguide	2.5 Gb/s, X-Cut, APE Waveguide
In-service device hours	> 100,000,000	> 300,000,000
FIT rate at 60% confidence	9	10
FIT rate at 95% confidence	30	21



prod- ucts, reduces performance variability, simplifies material requirements, reduces development time, and ultimately yields more manufacturable products in production. Through solid design rules and standardization of processes, LiNbO3 mod- ulator technology has rapidly transitioned from a laboratory research topic to high-volume manufacturing. Over the past five years, more than 100 000 LiNbO₃ modulator devices have been deployed in commercial fiber-optic communication systems.

VII. RELIABILITY

An important device performance parameter for LiNbO₃modulators is field reliability. Adequate field data are be- coming available to confirm and corroborate qualification and long-term reliability predictions. The field results demonstrate that stability; performance and reliability have reached levels only speculated of a few years ago. Table III shows actual field experience for two of the more common types of LiNbO₃modulators.

The calculated failure rates in Table III assume that field fail- ures are random and are best described by an exponential dis- tribution. The confidence intervals are calculated using a chi-

(b)100 C [19].

squared estimator. FIT stands for failures in time per 10 devicehours, i.e., parts per billion. As can be seen from the table, the field failure rates for the listed devices are extremely low.

One of the largest concerns during the development of $LiNbO_3$ technology was the issue of bias drift. Along with the availability of a significant amount of field data, the results from long-term accelerated aging studies are also becoming available. The results strongly suggest that bias drift is not a failure mechanism in properly designed and manufactured devices. Figs. 11–14 show the results of bias drift studies on a number of device types from different manufacturers. Clearly, all of these curves show excellent behavior.

Fig. 11(a) and (b) shows the drift of x-cut 2.5-Gb/s titanium-diffused waveguide devices at 85 and 100 C, respectively. Both sets exhibit asymptotic limiting behavior to values below a doubling of the initial bias voltage, the general figure of meritused for the fail criteria in long-term aging studies. Fig. 12 shows the drift in bias point (measured in degrees of phase) for x-cut 2.5-Gb/s APE waveguide devices also at 85 and 100

C. These are bias-free device designs, where the operating point at 0 V bias has been set to quadrature through specialized manufacturing processes, so bias voltage is, by definition, zero. Studies measuring the extinction ratio of pseudorandom bitstreams demonstrate that system performance is not affected

Fig. 11. Bias voltage drift for 2.5 Gb/s, x-cut, Ti modulators at (a) 85 and



(b)

Fig. 12. Phase drift for 2.5 Gb/s bias free, x-cut, APE modulators at (a) 85 and(b) 100 C [19].

Fig. 13. Bias voltage drift at various temperatures, 10 Gb/s, z-cut, Ti modulators, from Minford [55].

Fig. 14. Bias voltage drift at 85 C, 10 Gb/s, x-cut, Ti waveguides [19].

by phase drifts well beyond the values seen with these bias-freedesigns.

Fig. 13 shows data from the literature for z-cut 10-Gb/s titanium waveguide devices at various temperatures. These data also predict adequate reliability. Fig. 14 shows the drift of x-cut 10-Gb/s titanium waveguide devices at 85 C. The significant

characteristic of Fig. 14 is the trend toward 0 V rather than the usual increasing voltage with time. This strongly suggests that drift will not be a failure mechanism. The final curve, shown in Fig. 15, is the change in insertion loss for x-cut 2.5-Gb/s titanium waveguide devices at 85 C. As can be seen, loss changes are minimal as test time approaches 10 000 h. This loss stability is a direct indicator of the reliability of the fiber to modulator interface and a strong indicator of the optical circuit robustness.

There are many other reliability and qualification tests in addition to long-term aging studies. Telecordia TR-NWT-000 468 (formerly Bellcore) "Reliability assurance practices for optoelectronic devices in interoffice applications" [56] is the industry standard; however, it is about to be updated with GR-468-CORE "Generic reliability assurance requirements for optoelectronic devices used in telecommunications equipment" [57]. This updated version includes, for the first time, external modulators and consists of 13 different tests grouped into mechanical (mechanical shock, vibration, thermal shock, solderability, and fiber pull), endurance (accelerated aging, high temperature storage, low temperature storage, temperature cycling, damp heat, and cyclic moisture resistance), and special (internal moisture and electrostatic discharge threshold) cate- gories. It also distinguishes between hermetic and nonhermetic components as many of the device types in commercial use are not hermetic. Although passing a particular test does not quantify reliability, it does take into account the extensive experience of Telecordia as to what is important to reduce the risk of field failure problems. The data shown in Figs. 11, 12, and 14 are from qualification programs [19] in accordance with the Telecordia requirements.

VIII. SUMMARY

Fig. 15. Change in insertion loss with time, 85 C, 2.5 Gb/s, x-cut, Ti modulators [19].

LiNbO3 modulators have found widespread use in fiber-

optic communication systems, including both chirped and zero-chirp NRZ and RZ digital transmission formats. In addition, these integrated-optic devices have proven to be extremely reliable, and device-manufacturing technology has progressed to enable extensive deployment within digital and analog communication systems. As the complexity of fiber-optic transmission systems and networks continues to grow, the capabilities and benefits of LiNbO₃ modulators should continue to develop, thereby providing new solutions and enabling new architectures.

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